

	Hits	Search Text	DBs
34	23	((non\$4ionic\$4surfactant or (surface near5 active near5 agent) or surfactant) same "PC-6")	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
35	64	((non\$4ionic\$4surfactant or (surface near5 active near5 agent) or surfactant) same (apply\$4 or coat\$4 or layer or film)) and "PC-6"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
36	35	((non\$4ionic\$4surfactant or (surface near5 active near5 agent) or surfactant) same (apply\$4 or coat\$4 or layer or film)) and "PC-6" and (resist or photoresist)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
37	29	S41 NOT S42	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
38	46	((non\$4ionic\$4surfactant or (surface near5 active near5 agent) or surfactant)) and "PC-6" and (resist or photoresist or photocurable or photopolymerizable)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
39	66	"PC-6" and (resist or photoresist or photocurable or photopolymerizable)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
40	20	S45 NOT S44	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
41	207	((non\$4ionic\$4surfactant or (surface near5 active near5 agent) or surfactant) same (apply\$4 or coat\$4 or layer or film) same (polyoxyethylene near8 alkyl near9 ether)) and (resist or photoresist)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB